

	Type	L #	Hits	Search Text	DBs	Time Stamp	Comments
1	BRS	L1	81495	(clean or cleaning or cleaned or cleaner or cleanse or cleansing or cleansed) with (substrate or electronic or wafer or semiconductor or integrated adj3 circuit)	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOC R	2003/09/16 10:12	
2	BRS	L2	350630	(treat or treating or treated or treatment or etch or etching or etched or etchant) with (substrate or electronic or wafer or semiconductor or integrated adj3 circuit)	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOC R	2003/09/16 10:14	
3	BRS	L3	60521	(strip or stripping or stripped or stripper) with (substrate or electronic or wafer or semiconductor or integrated adj3 circuit)	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOC R	2003/09/16 10:14	
4	BRS	L4	38174	(wash or washing or washed) with (substrate or electronic or wafer or semiconductor or integrated adj3 circuit)	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOC R	2003/09/16 10:15	

	Type	L #	Hits	Search Text	DBs	Time Stamp	Comments
5	BRS	L5	6439	(propylene or dipropylene or tripropylene) adj3 (glycol) adj5 (butyl or alkyl or propyl or ethyl or methyl) adj5 ether	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOC R	2003/09/16 10:58	
6	BRS	L6	460352	11 or 12 or 13 or 14	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOC R	2003/09/16 10:19	
7	BRS	L7	33	16 with 15	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOC R	2003/09/16 10:39	
8	BRS	L8	22	17 and (heating or temperature)	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOC R	2003/09/16 10:25	

	Type	L #	Hits	Search Text	DBs	Time Stamp	Comments
9	BRS	L9	2	17 and (temperature adj3 cycle)	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOC R	2003/09/16 10:26	
10	BRS	L10	3	17 and (emulsion or microemulsion or micro-emulsion)	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOC R	2003/09/16 10:27	
11	BRS	L11	101	15 with (emulsion or microemulsion or micro-emulsion or immiscible)	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOC R	2003/09/16 10:28	
12	BRS	L12	2	111 same 16	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOC R	2003/09/16 10:28	

	Type	L #	Hits	Search Text	DBs	Time Stamp	Comments
13	BRS	L13	1748	16 with (emulsion or microemulsion or micro-emulsion or immiscible)	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOC R	2003/09/16 10:29	
14	BRS	L14	1655	16 with (emulsion or microemulsion or micro-emulsion)	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOC R	2003/09/16 10:28	
15	BRS	L15	2	114 same 15	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOC R	2003/09/16 10:28	
16	BRS	L16	54	15 with (azeotrop\$)	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOC R	2003/09/16 10:29	

	Type	L #	Hits	Search Text	DBs	Time Stamp	Comments
17	BRS	L17	26	116 and 16	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOC R	2003/09/16 10:29	
18	BRS	L18	118	16 same 15	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOC R	2003/09/16 10:39	
19	BRS	L19	47	118 same (heating or temperature or centigrade or celsius or Fahrenheit)	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOC R	2003/09/16 10:58	

	Type	L #	Hits	Search Text	DBs	Time Stamp	Comments
20	BRS	L20	40736 3	(soften or softening or softened or swell or swelling or swelled or dissolve or dissolving or dissolved or dissolution or strip or stripping or stripped or stripper or etch or etching or etched or etchant or remove or removing or removed or removal) with (flux or photoresist or resist or resin or solder adj3 paste)	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOC R	2003/09/16 10:57	
21	BRS	L21	81528	(eliminate or eliminated or eliminating or elimination or clean or cleaning or cleaned or cleaner or cleanse or cleansing or cleansed or cleanser) with (flux or photoresist or resist or resin or solder adj3 paste)	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOC R	2003/09/16 11:00	
22	BRS	L22	6461	(propylene or dipropylene or tripropylene or di-propylene or tri-propylene) adj5 (glycol) adj5 (butyl or alkyl or propyl or ethyl or methyl) adj5 ether	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOC R	2003/09/16 14:40	

	Type	L #	Hits	Search Text	DBs	Time Stamp	Comments
23	BRS	L23	291	122 with (heating or temperature or centigrade or celsius or Fahrenheit or heated)	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOC R	2003/09/16 11:13	
24	BRS	L24	452734	120 or 121	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOC R	2003/09/16 11:00	
25	BRS	L25	40	124 same 123	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOC R	2003/09/16 11:11	
26	BRS	L26	18636	(organic adj3 (solvent or mixture or fluid or liquid)) with (emulsion or micro-emulsion or micro adj3 emulsion)	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOC R	2003/09/16 11:12	

	Type	L #	Hits	Search Text	DBs	Time Stamp	Comments
27	BRS	L27	987	126 same 124	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOC R	2003/09/16 11:15	
28	BRS	L28	639	126 with 124	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOC R	2003/09/16 11:12	
29	BRS	L29	1304	126 with (heating or temperature or centigrade or celsius or Fahrenheit or heated)	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOC R	2003/09/16 14:42	
30	BRS	L30	182	129 same 124	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOC R	2003/09/16 11:18	

	Type	L #	Hits	Search Text	DBs	Time Stamp	Comments
31	BRS	L31	0	130 and 122	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOC R	2003/09/16 11:15	
32	BRS	L32	190687	(134/\$ or 252/\$ or 510\$).ccls.	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOC R	2003/09/16 11:15	
33	BRS	L33	2	130 and 132	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOC R	2003/09/16 11:17	
34	BRS	L34	67723	16 same 124	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOC R	2003/09/16 11:17	

	Type	L #	Hits	Search Text	DBs	Time Stamp	Comments
35	BRS	L35	2	129 same 134	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOC R	2003/09/16 11:18	
36	BRS	L36	15	129 and 134	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOC R	2003/09/16 11:20	
37	BRS	L37	47	wack-o\$.in.	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOC R	2003/09/16 11:20	
38	BRS	L38	421	122 with (solubility or miscibility or miscible or soluble) with (water or "H2O" or "H.sub.2O")	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOC R	2003/09/16 14:48	

	Type	L #	Hits	Search Text	DBs	Time Stamp	Comments
39	BRS	L39	20	138 with (heating or temperature or centigrade or celsius or Fahrenheit or heated)	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOC R	2003/09/16 14:48	
40	BRS	L40	447	122 with (solubility or miscibility or miscible or soluble or emulsion or micro-emulsion or micro adj3 emulsion) with (water or "H2O" or "H.sub.2O")	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOC R	2003/09/16 14:57	
41	BRS	L41	21	140 with (heating or temperature or centigrade or celsius or Fahrenheit or heated)	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOC R	2003/09/16 14:59	
42	BRS	L42	449	122 with (solubility or miscibility or miscible or soluble or emulsion or micro-emulsion or micro adj3 emulsion or homogeneous) with (water or "H2O" or "H.sub.2O")	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOC R	2003/09/16 14:58	

	Type	L #	Hits	Search Text	DBs	Time Stamp	Comments
43	BRS	L43	21	142 with (heating or temperature or centigrade or celsius or Fahrenheit or heated)	USPAT; US-PGPUB ; EPO; JPO; DERW ENT; IBM_ TDB; USOCR	2003/09/16 14:59	